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Large spin accumulation and crystallographic dependence of spin transport in single crystal gallium nitride nanowires

Tae-Eon Park¹, Youn Ho Park^{1,2}, Jong-Min Lee¹, Sung Wook Kim², Hee Gyum Park^{1,3}, Byoung-Chul Min^{1,3}, Hyung-jun Kim¹, Hyun Cheol Koo^{1,4}, Heon-Jin Choi², Suk Hee Han¹, Mark Johnson⁵ & Joonyeon Chang^{1,3}

Semiconductor spintronics is an alternative to conventional electronics that offers devices with high performance, low power and multiple functionality. Although a large number of devices with mesoscopic dimensions have been successfully demonstrated at low temperatures for decades, room-temperature operation still needs to go further. Here we study spin injection in single-crystal gallium nitride nanowires and report robust spin accumulation at room temperature with enhanced spin injection polarization of 9%. A large Overhauser coupling between the electron spin accumulation and the lattice nuclei is observed. Finally, our single-crystal gallium nitride samples have a trigonal cross-section defined by the (001), (11 $\bar{2}$) and ($\bar{1}\bar{1}2$) planes. Using the Hanle effect, we show that the spin accumulation is significantly different for injection across the (001) and ($\bar{1}\bar{1}2$) (or (11 $\bar{2}$)) planes. This provides a technique for increasing room temperature spin injection in mesoscopic systems.

¹Center for Spintronics, Post-Si Semiconductor Institute, Korea Institute of Science and Technology, Hwarangno 14-gil 5, Seongbuk-gu, Seoul 02792, Korea. ²Department of Materials Science and Engineering, Yonsei University, Seoul 03722, Korea. ³Department of Nanomaterials Science and Engineering, Korea University of Science and Technology, Daejeon 34113, Korea. ⁴KU-KIST Graduate School of Converging Science and Technology, Korea University, Seoul 02841, Korea. ⁵Naval Research Laboratory, Washington, District Of Columbia 20375, USA. Correspondence and requests for materials should be addressed to J.C. (email: presto@kist.re.kr).

Recent basic research advances in spintronics have occurred at cryogenic temperature^{1–3} and include the realization of a spin-injected field-effect transistor and the observation of a gate-voltage-controlled conductance oscillation^{4,5}. Numerous other devices with mesoscopic dimensions have demonstrated attractive properties for decades^{6–10}. Recently, there have been a few meaningful achievements in spintronic devices at room temperature, such as a highly doped Si channel with tunnel contacts, a Heusler alloy/*n*-gallium arsenide spin valves, a spin logic device based on graphene and a gallium nitride (GaN)-based spin laser and spin valves^{11–17}. However, the robust demonstration of spin transport in semiconductor devices at room temperature has remained elusive. Requirements for viable devices include a high spin-dependent resistance modulation, relatively low electrode contact and channel resistances, and a long spin diffusion length in a device with channel dimensions of tens of nanometres.

Here we demonstrate that single crystal GaN nanowires (NWs) show remarkably good room-temperature spin transport characteristics. Of greater importance, we observe a strong difference in spin accumulation for injection across the (001) and ($\bar{1}\bar{1}2$) (or (11 $\bar{2}$)) planes.

Results

NW spin valve devices and measurement configurations. The spin injection technique^{18–20} using the lateral nonlocal spin valve (NLSV) geometry is described in Fig. 1a, showing a GaN NW (red) and ferromagnetic thin-film electrodes. Biased with current I , a steady-state non-equilibrium population of polarized spins, spin accumulation $\tilde{M}$, builds up near the F2/NW interface and diffuses along the NW. A voltage $V_S \propto \tilde{M}$, measured between spin detector F1 and an electrode at the far left end, depends on the relative magnetization orientations M1 and M2 of F1 and F2, respectively^{4,18}. The ferromagnetic electrodes have different widths (300 and 600 nm) to ensure that portions of F1 and F2 in the *x*-*y* plane have different values of coercivity, $H_{C1} \neq H_{C2}$, so that ranges of field exist with M1 and M2 antiparallel when external field H_y is swept between -2.0 and 2.0 kOe.

Our GaN NWs are prepared by chemical vapour deposition and have lateral dimensions of about 80 nm with high uniformity along the entire length (Methods and Supplementary Note 1). Figure 1b shows a cross-section sketch of the NW and the ferromagnetic electrode formed as a tunnel junction, GaN/MgO/CoFeB/Ta/Ru. To investigate the structure of this junction in detail, cross-sectional samples were prepared by focused ion beam slicing and a lift-off process with a micromanipulator. Cross-sectional high-angle annular dark field images of two junctions, in a scanning transmission electron microscopy mode taken at the $[110]$ zone axis, are shown in Fig. 1c,d.

The triangular cross-section of GaN NWs provides locally planar interfaces on two facets²¹. The MgO layer is uniform and free of pinholes, thus ensuring high spin injection/detection efficiency^{8,10}. The transmission electron microscopy analyses of the cross-sections (insets of Fig. 1c,d) identify the three facets as (001), (11 $\bar{2}$) and ($\bar{1}\bar{1}2$). The selected area electron diffraction and high-resolution transmission electron microscopy analyses confirm that there are two uniquely different kinds of devices in our studies, characterized by the crystallographic planes that contact the ferromagnetic electrodes (Fig. 1c,d and Supplementary Fig. 3): the ($\bar{1}\bar{1}2$) and (001) planes (Fig. 1c; type-C device) and the (11 $\bar{2}$) and ($\bar{1}\bar{1}2$) planes (Fig. 1d; type-D device).

Electrical measurements of a top gated GaN device with four electrodes showed the NW resistivity to be quite low, 1.7 and 1.6 m Ω cm at 1.8 and 300 K, respectively (Supplementary Note 1).

Weak gate modulation, the temperature dependence of the resistance and low contact resistance were observed. These characteristics confirm that the GaN NWs are highly degenerate *n*-type semiconductors²² (Supplementary Fig. 4), behaviour that has been explained by the presence of nitrogen vacancies and/or oxygen impurities²³.

NLSV magnetoresistance measurements. Data from a non-local magnetoresistance (MR) measurement with field H_y applied along the *y* axis of device 01 (type-C device) over a large field range are shown in Fig. 2a. Several independent effects of spin accumulation are identified and introduced. Although H_y is in the plane of the substrate, the injection and detection regions of the ferromagnetic films are in planes at angle $\pm 60^\circ$ to the *y* axis and magnetization anisotropies control the local magnetization orientations. The saturation magnetization of thin CoFeB films is $4\pi M_s = 11$ kOe. A strong shape anisotropy forces the magnetization orientation M to lie in the film plane for field $H_y \ll 4\pi M_s$, whereas fields $H_y > 4\pi M_s$ are sufficiently large that M always aligns parallel with H_y . For $|H_y| > 12$ kOe (Fig. 2a), both M1 and M2 are aligned with H for all portions of the films. The injected spins also are aligned with H , there is no spin precession and the detector voltage measures the full, positive value of spin accumulation $\tilde{M}$.

For the range $2 \text{ kOe} < |H_y| < 12 \text{ kOe}$, the in-plane shape anisotropy competes with the external field and the magnetization component in the plane of the film increases as $|H_y|$ decreases. The red trace in Fig. 2b shows the region $-2 \text{ kOe} < H_y < 2 \text{ kOe}$ where the in-plane anisotropy dominates. Magnetizations M1 and M2 are in the film plane, but different portions of the injector and detector films in contact with the NW may have different vector orientations. In this field region, three separate features of spin accumulation are identified. First, narrow hysteretic dips are observed at $|H_y| \approx 250$ Oe, where M1 and M2 reverse orientations by 180° . Noting a baseline offset²⁴ of about 5Ω , the magnitude of the MR dip, $\Delta R_S = 2R_S \approx 38 \Omega$ at 1.8 K is consistent with the magnitude of $\tilde{M}$ measured at $|H_y| = 20 \text{ kOe}$: $R_S \approx 20 \Omega$. It follows that the local orientations of M1 and M2 are antiparallel during the re-orientation and, regardless of the unusual topography, measuring R_S using MR dips is a good representation of $\tilde{M}$. Second, data for up- and down-sweep traces in Fig. 2b are nearly identical for the field range $|H_y| > 250$ Oe but show hysteresis for the range $|H_y| < 250$ Oe. Broad curves in this field range will be analysed using a model of spin accumulation and Hanle effect. Electron spin accumulation $\tilde{M}$ can transfer spin angular momentum to the lattice nuclei through an Overhauser coupling^{25–31}. Nuclear spin polarization appears as an effective magnetic field, H_n , that causes a hysteretic field shift of the Hanle line shape. Third, smooth and continuous traces are formed after adjusting the data to account for Overhauser shifts. These traces are matched with Hanle fitting functions below. The deduced spin relaxation times agree with the data and analysis in the narrow hysteretic dips. We use the Hanle data to show that type-C and type-D devices have very different spin transport characteristics: spin injection is robust at (11 $\bar{2}$) and ($\bar{1}\bar{1}2$) interfaces but is weak at the (001) interface.

Temperature and channel length dependences of spin signal.

We begin with a study of $\tilde{M}$ by analysing the MR dips. Non-local MR data are shown in Fig. 2c for a large temperature range, $10 \text{ K} \leq T \leq 300 \text{ K}$. Our first significant result is a very large value of spin accumulation, $\Delta R_S = 38 \Omega$ (1.8 K), which persists at room temperature, $\Delta R_S = 16 \Omega$ (Fig. 2d). As the highly degenerate GaN NW has low room-temperature resistivity, the ratio of $\tilde{M}$ to

Figure 1 | A lateral spin valve device with gallium nitride channel. (a) False-coloured scanning electron microscopy (SEM) image of a device (scale bar, 1 μm). The centre-to-centre channel length is $L = 1 \mu\text{m}$. For measurements of MR dips, magnetic field H is applied along the easy axis (y axis) of spin detector F1 and spin injector F2. In studies of the Hanle effect, field H may be applied along x , y or z , or in the y - z plane at angle θ to z . (b) Schematic cross-sectional view of ferromagnetic electrode in contact with the GaN NW. (c,d) High-angle annular dark field images in scanning transmission electron microscopy mode showing views at the interface between the ferromagnetic tunnel electrode and GaN NW for two types of devices. Scale bars, 40 nm (c,d). The insets are the electron diffraction patterns with $[1\bar{1}0]$ zone axis of the corresponding images with scale bars 5 nm^{-1} . The selected area electron diffraction patterns show the surfaces of each GaN NW to have (001), $(11\bar{2})$ and $(\bar{1}\bar{1}2)$ planes. (c) The $(\bar{1}\bar{1}2)$ and (001) planes contact the ferromagnet in one device type (type-C device), whereas (d) the $(11\bar{2})$ and $(\bar{1}\bar{1}2)$ planes contact the ferromagnet in the second device type (type-D device).

Figure 2 | NLSV MR data. (a) Non-local MR measurement with field H_y applied along the y axis of device O1 (type-C device) at $T = 1.8 \text{ K}$. $I = +1 \mu\text{A}$. (b) Expanded field range near $H_y = 0$. (c) NLSV voltage dips ΔV_s were measured at several different temperatures with a current of $+1 \mu\text{A}$. (d) Temperature dependence of the amplitudes of ΔV_s . The error bars in d indicate the s.d. from multiple measurements.

channel resistance R_C is high, $\Delta R_S/R_C \sim 0.006$ (0.003) at 1.8 K (300 K). In the temperature-dependent measurements of ΔR_S , there is a possibility that the interfacial spin scattering may have

played an important role in the analysis of NLSV signals³². To elucidate the effect in our system, we have investigated a temperature-dependent asymmetry between R_S at parallel and

Figure 3 | Spin injection of two typed devices at room temperature.

(a) Nonlocal MR measurement $R_S(H_y)$ with field H_y applied along the y axis (inset) of device O2 (type-D). Green (blue) trace: field sweep down (up). Red trace: data are modified for Overhauser shifts and omission of dips, then shifted up for clarity. No Hanle feature is observed. (b) $R_S(H)$ for device O3 (type-C), with H applied along an axis in the y - z plane at angle 30° to z (the inset). Green (blue) trace: field sweep down (up). Red trace data are modified for Overhauser shifts, omission of dips and shifted for clarity (Supplementary Note 4). $T = 300$ K.

antiparallel configuration, indicating that the interfacial spin scattering effect is negligible even at room temperature in our device with a GaN NW (Supplementary Note 3). Spin accumulation is not usually observed in semiconductors at room temperature because of rapid spin relaxation^{8,29,33,34}. The observation of large ΔR_S at room temperature in our GaN NWs implies long spin relaxation times, confirmed by the Hanle data presented below. The spin diffusion length λ_S was measured directly by fabricating a NLSV device (type-C device) with multiple ferromagnetic electrodes and several injector/detector separations, L (Supplementary Note 4). In the NLSV devices with multiple ferromagnetic electrodes, the spin absorption (spin sink) effect should be considered^{35,36}. However, this effect cannot affect the estimate of spin transport characteristics in our devices, because the MgO tunnelling layer has high resistance (Supplementary Note 4). Measurements of $\Delta R_S(L)$ showed an exponential decrease $\exp(-L/\lambda_S)$ with a fitted value of $\lambda_S = 710 \pm 90$ nm (300 K). The average polarization P of the ferromagnetic electrodes³⁷ is found to be $8.9 \pm 0.5\%$ (300 K). For the entire set of samples, P ranged from 9.4 to 13% (300 K; Supplementary Table 1).

Hysteretic field shift of spin signal. The Overhauser coupling between spin accumulation and nuclear spins is described in Supplementary Note 5. A large Overhauser coupling of GaN NWs is related to the large spin accumulation in the confined

Figure 4 | Difference in spin transport of crystallographic planes. All data sets are modified for Overhauser shifts of $\pm H_n$ and omission of MR dips (Supplementary Note 4). (a) $R_S(H)$ for device O3 (type-C), with H applied along an axis in the y - z plane at angle 30° to z (refer to inset). The small baseliner resistance measured in Fig. 3a is subtracted from the red trace in Fig. 3b. The residual data are plotted and fit to a purely absorptive Hanle shape function. These data show that the Hanle effect derives from spins injected at the right (001) interface. (b) H is applied along an axis to 150° (refer to inset) and the trace is fit with a mixture of absorptive (40%) and dispersive (60%) Hanle shape functions. The Hanle effect derives from spins injected at the left ($\bar{1}\bar{1}\bar{2}$) interface. (c) Field H is applied along the y -axis for device O1. The fit is for 60% absorptive and 40% dispersive components. Compare with data under the same conditions for a type-D device (red trace, Fig. 3a) where no Hanle effect is observed. All data were obtained at 300 K.

geometry and highly efficient dynamic nuclear polarization of a Ga interstitial impurity²⁹. By recognizing hysteretic shifts of field, by an amount $\pm H_n$, we combine sections of up- and down-sweeps to create smooth curves, $\Delta R_S(H)$.

Hanle effect in NLSV MR. We analyse these magnetic field traces $\Delta R_S(H)$ using Hanle shape functions to fit the data. In most prior

work with bulk and thin film samples, the non-magnetic channel and the ferromagnetic electrodes of the NLSV devices are coplanar^{1,4,12,20,38}. NLSVs with GaN NW channels represent a specific device category with a geometry that is not coplanar. Each ferromagnetic electrode makes interfacial contact with two of the triangular faces and neither face is in the substrate plane. Each electrode may have one of a variety of local micromagnetic configurations and the injected spins generally will not have orientations that are coplanar with a detecting interface. Although we cannot know the details of the local magnetization orientations of the portions of spin injector and detector films in contact with the NWs, we show that a combination of absorptive and dispersive Hanle shape functions³⁹ can fit any trace (Supplementary Note 6).

Discussion

The inset of Fig. 3a shows an example in which the ferromagnetic electrode magnetization is continuous across the top of a type-D NW. Spin-polarized carriers injected at the left (right) face will be oriented in the y - z plane, along an axis 30° (-30°) to z . The resulting spin accumulation $\tilde{M}$ can be described as two populations in the y - z plane, each with a unique vector. In this case, there is equal spin injection from the two interfaces $[(11\bar{2})$ and $(\bar{1}\bar{1}2)]$, the z -component of spin cancels and the net spin accumulation $\tilde{M}$ (red arrow in inset) is described as a vector along y .

Figure 3a shows $\Delta R_S(H_y)$ for field applied along the y -axis. With $\tilde{M}$ along y , there is no torque on the spins and no Hanle effect is observed. The usual MR dips are recorded and the Overhauser shift is negligible. When the dips are removed, a small, V-shaped background resistance is observed (red trace) and can be associated with magnetization M1 and M2 tipping slightly out of the film plane. These data confirm that left and right interfaces $[(11\bar{2})$ and $(\bar{1}\bar{1}2)]$ inject spins with equal efficiency.

In a different case, field H is applied along an axis in the y - z plane and at an angle 30° to z (Fig. 3b, inset). No torque is applied to spins injected from the left interface, but spins injected from the right will show a Hanle effect. Figure 3b shows $\Delta R_S(H)$ for a type-C device along an axis in the y - z plane and $\theta = 30^\circ$ from z . The red trace has been modified to correct for Overhauser shifts and to omit the narrow dips. The resulting curve deviates from the red trace in Fig. 3a. To study the difference, we fit the V-shape trace (Fig. 3a) and subtract this background from the red trace in Fig. 3b. The residual plot is shown in Fig. 4a (note change of scale). The black line is a fit to the absorptive Hanle shape function³⁹ (Supplementary Note 7). In our model of separate spin populations from the left and right interfaces, the magnetization orientations of the injecting and detecting ferromagnetic electrodes at the left interfaces, M1L and M2L, respectively, have dominant components along the 30° axis. These injected spins are oriented along the same axis as the magnetic field and never precess. For this type-C device, the observed Hanle curve must be the result of spin injection at the right (001) interface.

Figure 4b shows $\Delta R_S(H)$ with field H applied to the same device at an axis 150° to z . Here field H is parallel with the axis of spins injected from the right interface. These spins show no precession and no Hanle effect at the right (001) interface. The observed Hanle effect must derive from spin injection from the left $(\bar{1}\bar{1}2)$ interface. The data are fit to a mix of dispersive (60%) and absorptive (40%) shape functions with amplitude of 5 Ω . Note that the Hanle feature that results from spin injection at the (001) interface is much smaller than the feature that results from spin injection at the $(\bar{1}\bar{1}2)$ interface, an amplitude ratio of 0.4 for the data in Fig. 4a,b. The data in Fig. 4c show the Hanle feature

when H is applied along the y axis (device 01, Fig. 2c). Field H_y is not collinear with the axes of spins injected from either interface and the Hanle curve differs from that in Fig. 4b. Comparison of Fig. 4c with the same experimental conditions for a type-D device (red trace, Fig. 3a) dramatically illustrates the very different spin transport characteristics of the (001), $(11\bar{2})$ and $(\bar{1}\bar{1}2)$ interfaces. These characteristics reproduced in our study of eleven type-C devices and six type-D devices. Examples of data and fits for other field configurations are shown in Supplementary Note 8. For a given device, fitting parameter T_2 (spin relaxation time) showed little variation with temperature for $T = 1.8$ and 300 K. For all fits, values of T_2 were in the range 100–150 ps, which is comparable to the reported values^{17,40} (Supplementary Table 1).

These spin behaviours suggest that spin accumulation strongly depends on the interface where spin injection occurs. Wurtzite crystals exhibit non-zero spontaneous polarization resulted from the Ga- or N- face crystal plane of GaN. Transport properties of GaN are known to be largely dependent on the spontaneous polarization which is ten times larger than in conventional III-V semiconductor compounds^{41,42}. The triangular geometry of our GaN NWs provides interfacial conditions that permit observation of the unique spin transport behaviour shown in Figs 3 and 4. Spontaneous polarization in GaN can cause electric fields up to 3 MV cm^{-1} ($= 0.3 \text{ V nm}^{-1}$)⁴¹. One polar face at the (001) interface and two semi-polar faces at the $(\bar{1}\bar{1}2)$ and $(11\bar{2})$ interfaces yield different magnitudes of electric field. Moreover, we speculate that the different interfaces, the (001) and $(\bar{1}\bar{1}2)$ [or $(11\bar{2})$] planes, may alter the effect of the interface-specific spin filtering or the strength of the spin-orbit coupling⁴³. A combination of these effects may cause the significant differences of spin injection at the (001) and $(\bar{1}\bar{1}2)$ interfaces that result in the unusual spin accumulation observed in Figs 3 and 4.

In summary, we have studied electrically injected and detected spin transport in trigonal single-crystal GaN NWs and demonstrated robust spin injection and accumulation. The spin modulation resistance is large, $\Delta R_S = 16.1 \Omega$ at room temperature. Because of the low NW resistivity (order of $10^{-3} \Omega \text{ cm}$), the ratio of spin dependent modulation to channel resistance, $\Delta R_S/R_C \sim 10^{-3}$, is much higher than has been observed in other semiconductor materials. Remarkably, the room temperature spin transport parameters are comparable with, or larger than, values for aluminium (Al) films at cryogenic temperature: λ_S (GaN NW, 300 K) = $710 \text{ nm} \sim \lambda_S$ (Al, 4 K) = 800 nm and T_2 (GaN NW, 300 K) = $150 \text{ ps} > T_2$ (Al, 4 K) = 110 ps (ref. 44). These characteristics are promising for room temperature mesoscopic spintronic devices. A large Overhauser coupling between the conduction electron spin accumulation and the lattice nuclear spins was observed. Of greater interest, we demonstrated a large difference in the spin accumulation of different crystallographic planes. This opens possibilities to tune interfaces for optimized spin transport in mesoscopic devices.

Methods

NW growth. GaN NWs were synthesized in horizontal chemical vapour deposition system through vapour-liquid-solid mechanism using Au catalyst. Solid metallic Ga (purity 99.99%) was subsequently inserted in front of each substrate. The temperature of the furnace was increased at a rate of $50^\circ \text{C min}^{-1}$ to 850°C . Flows of NH_3 and H_2 served as carrier and reactant gases at a rate 10 and 350 standard cubic centimetres per minute, respectively. The temperature was maintained for 120 min. and then cooled down to room temperature.

NW-based device fabrication. A single GaN NW was picked up and transferred to a pre-patterned p^+ Si substrate ($\rho \sim 0.01 \Omega \text{ cm}$) coated with 300 nm-thick of silicon oxide. The native oxide of the NW was removed with a hydrofluoric acid (deionized water/hydrofluoric acid (HF) 30:1 v/v) dip for 30 s. Electrical contacts (Ti/Au, 5/80 nm) were then formed by electron beam lithography and lift-off. A top gate structure consisting of an Al_2O_3 (30 nm) gate oxide and a Ti/Au (5/100 nm) top gate was formed on top of this NW using electron beam lithography

followed by a lift-off process without wet etching (Supplementary Fig. 4). The fabrication of the NLSV devices was carried out with a two-step process. The first step was formation of the ferromagnetic spin injector and detector, and the second step was fabrication of the non-magnetic electrodes. In the first step, the surface oxide of the GaN NW was removed with a hydrofluoric acid dip and a 1.5 nm thick MgO tunnel barrier and 30 nm-thick CoFeB electrodes were subsequently deposited in a DC magnetron sputter system. The MgO layer is uniform and free of pinholes, ensuring high spin injection/detection efficiency^{8,9,45}. Next, a Ta/Ru (5/5 nm) bilayer was deposited as a cap to prevent surface oxidation of the CoFeB. For the second step, a Ti/Au (5/100 nm) bilayer was deposited using DC magnetron sputtering after a brief Ar ion mill etch eliminated the oxide layer on the NW surface. All deposition procedures were performed *in-situ* without breaking vacuum. Electrical measurements of fabricated devices were carried out with a physical property measurement system (PPMS 9T, Quantum Design, Inc.) at stable temperatures in the range $1.8\text{ K} \leq T \leq 300\text{ K}$.

Micromagnetic simulations. Micromagnetic simulations shown in Supplementary Note 6 were performed using the Object-Oriented MicroMagnetic Framework developed by NIST⁴⁶. The equilibrium magnetization configurations were obtained using a conjugate gradient algorithm with the Fletcher-Reeves method. The sample dimensions were $600 \times 14,000 \times 30\text{ nm}^3$ as the spin injector (F2) and $300 \times 21,600 \times 30\text{ nm}^3$ as the spin detector (F1) and the unit cell size was $3 \times 3 \times 3\text{ nm}^3$. The material parameters used are an exchange stiffness $A_{\text{ex}} = 2.83 \times 10^{-11}\text{ J m}^{-1}$ and saturation magnetization $M_s = 1.034 \times 10^6\text{ A m}^{-1}$.

Data availability. The data that support the findings of this study are available from the corresponding authors on request.

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Author contributions

J.C. planned the experiment and supervised the research. T.-E.P. and J.C. fabricated the devices and collected the data. S.W.K. and H.-J.C. synthesized GaN NWs. Y.H.P., H.G.P., B.-C.M., H.-j.K., H.C.K. and S.H.H. analysed the data. J.-M.L. performed micromagnetic simulations using OOMMF. T.-E.P., J.C. and M.J. analysed the data and wrote the manuscript with help from all co-authors.

Additional information

Supplementary Information accompanies this paper at <http://www.nature.com/naturecommunications>

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